



# UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE  
United States Patent and Trademark Office  
Address: COMMISSIONER FOR PATENTS  
P.O. Box 1450  
Alexandria, Virginia 22313-1450  
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/988,651	11/20/2001	David L. Larkin	TI-23422.1	8936

23494 7590 03/06/2007  
TEXAS INSTRUMENTS INCORPORATED  
P O BOX 655474, M/S 3999  
DALLAS, TX 75265

EXAMINER
----------

ANYA, IGWE U

ART UNIT	PAPER NUMBER
----------	--------------

2891

SHORTENED STATUTORY PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE
3 MONTHS	03/06/2007	PAPER

**Please find below and/or attached an Office communication concerning this application or proceeding.**

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

# Office Action Summary

Application No.

09/988,651

Applicant(s)

LARKIN ET AL.

Examiner

Igwe U. Anya

Art Unit

2891

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

## Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

## Status

- 1) ☒ Responsive to communication(s) filed on 05 October 2006.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

## Disposition of Claims

- 4) ☒ Claim(s) 12-29 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 12-29 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

## Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 20 November 2001 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.  
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

## Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some \* c) ☐ None of:
- ☐ Certified copies of the priority documents have been received.
  - ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
  - ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

\* See the attached detailed Office action for a list of the certified copies not received.

## Attachment(s)

- |  |   |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)                                | 4) <input type="checkbox"/> Interview Summary (PTO-413)<br>Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)                       | 5) <input type="checkbox"/> Notice of Informal Patent Application                       |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO/SB/08)<br>Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____  |

### **DETAILED ACTION**

1. The finality of the rejection of the last Office action is withdrawn.
2. The indicated allowability of claims 15 – 19 and 24 - 28 is withdrawn in view of new matter. The rejection follows:
3. In view of the Appeal Brief filed on June 6, 2006 PROSECUTION IS HEREBY REOPENED. A New ground or rejection is set forth below.

To avoid abandonment of the application, appellant must exercise one of the following two options:

- (1) file a reply under 37 CFR 1.111 (if this Office action is non-final) or a reply under 37 CFR 1.113 (if this Office action is final); or,
- (2) initiate a new appeal by filing a notice of appeal under 37 CFR 41.31 followed by an appeal brief under 37 CFR 41.37. The previously paid notice of appeal fee and appeal brief fee can be applied to the new appeal. If, however, the appeal fees set forth in 37 CFR 41.20 have been increased since they were previously paid, then appellant must pay the difference between the increased fees and the amount previously paid.

### ***Claim Rejections - 35 USC § 112***

4. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

5. Claims 21 – 29 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter, which was not described in the specification in such a way as to reasonably convey to

Art Unit: 2891

one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. The limitation "substantially saturates" in line 7 of independent claim 12, and line 6 of independent claim 21 constitute new matter.

6. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter, which the applicant regards as his invention.

7. Claims 12 – 29 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

8. The term "substantially saturates" in claims 12 and 21 is a relative term, which renders the claim indefinite. The term "substantially saturates" is not defined by the claim, the specification does not provide a standard for ascertaining the requisite degree, and one of ordinary skill in the art would not be reasonably apprised of the scope of the invention. Dependent claims 13 – 20 and 22 – 29 are also rendered indefinite.

### ***Claim Rejections - 35 USC § 102***

9. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

10. The changes made to 35 U.S.C. 102(e) by the American Inventors Protection Act of 1999 (AIPA) and the Intellectual Property and High Technology Technical Amendments Act of 2002 do not apply when the reference is a U.S. patent resulting directly or indirectly from an international application filed before November 29, 2000. Therefore, the prior art date of the reference is determined under 35 U.S.C. 102(e) prior to the amendment by the AIPA (pre-AIPA 35 U.S.C. 102(e)).

11. Claims 12 – 14, 20, 21 – 23, and 29 are rejected under 35 U.S.C. 102(e) as being anticipated by Ino et al. (US Patent 5888839).

12. Ino et al teach a semiconductor device (figs. 7), comprising:  
a semiconductor device having at least one metal layer (47, 49) completed;  
a planarizing dielectric layer (48, 50) on top of the semiconductor device; and  
wherein the semiconductor has diffused hydrogen (fig. 7O element 42, col. 10 lines 16 – 20).

13. The process limitations have been given patentable weight in accordance with the well-established product-by-process doctrine. The presence of process limitations on a product claim, which product does not otherwise patentably distinguish over prior art, cannot impart patentability to the product. In re Stephens 145 USPQ 656 (CCPA). Subsequent diffusion does not require the Final Product to be completely or substantially saturated. Claim 12 recites the limitation of “providing a hydrogen treatment until hydrogen diffuses throughout and substantially saturates the semiconductor device.” This language is directed towards the method of making the device, but does not necessarily limit the final structure. The final product does not

Art Unit: 2891

necessarily have to be saturated with hydrogen or even substantially saturated, because hydrogen diffuses out of semiconductor device over time.

14. Claims 21 – 23 are rejected under 35 U.S.C. 102(b) as being anticipated by Mora (US Patent 4920077).

15. Mora teaches a semiconductor device, comprising:

a semiconductor device having at least one metal layer completed (col. 4 lines 22 – 47);

a hydrogen treated semiconductor device (col. 4 lines 48 – 54); and

wherein the semiconductor device has diffused hydrogen (col. 4 lines 48 – 54).

16. Claims 12 – 14, 19 – 23, 28 and 29 are rejected under 35 U.S.C. 102(e) as being anticipated by Chen et al. (US Patent 5866945).

17. Chen et al teach a semiconductor device (fig. 5), comprising:

a semiconductor device having at least one metal layer (51) completed;

a planarizing dielectric layer comprising HSQ film (52), TEOS film (53) and a dielectric film (54) on top of the semiconductor device; and

wherein the semiconductor has 87% - 90% Si-H bonds from plasma diffused hydrogen (col. 5 line 11 – 30) & col. 6 lines 60 – col. 7 lines 29).

***Claim Rejections - 35 USC § 103***

18. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the

invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

19. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

20. Claims 15 – 18 and 24 - 27 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chen et al. (5866945).

21. Chen et al. teach the features previously outlined, but lack the order in which the HSQ and TEOS are arranged in the dielectric stack.

22. However, it would have been obvious to one of ordinary skill in the art at the time the invention was made to rearrange the order of the dielectric for production optimization. Rearranging parts of an invention involves routine skill in the art. In re Japikse USPQ 70.

#### ***Remarks***

23. In light of the 112-1<sup>st</sup> paragraph, 2nd paragraph and product-by-process issues noted above, “substantially saturates” is being interpreted to mean that at least a portion of the semiconductor device includes at least some level of hydrogen, regardless of whether the device is completely saturated with hydrogen.

24. Applicant cited Standard Oil, 206 USPQ 676 (D.C. Delaware 1980) in the Appeal Brief for the proposition that the term “substantial” is synonymous with the term “completely.” This argument is not persuasive because Standard Oil did not hold this. Rather, the Standard Oil court held that “[t]he description requirement...does not mandate in haec verba repetition of the formal language of the [interference] Count.” Rather, “the application [must] describe the product in language that is legally equivalent to that of the Count.” *Id.* at 714. The court then went on to provide an explanation of why the specification did provide support for employing language of the Count “substantial crystallinity.” *Id.* Nothing in the Standard Oil decision indicates that the meaning of “substantially (saturates)” is identical to that of “completely (saturates).”

25. Applicant's arguments with respect to claims have been considered but are moot in view of the new ground(s) of rejection. Applicant's amendment filed January 30, 2006 necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL.** See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

26. A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of



the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

**Contact Information**

27. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Igwe U. Anya whose telephone number is (571) 272-1887. The examiner can normally be reached on M - F 8:30am - 5:00pm.

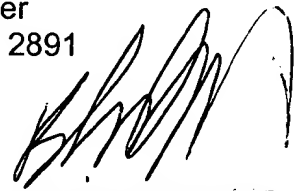
28. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, William B. Baumeister can be reached on (571) 272-1722. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

29. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Igwe U. Anya  
Examiner  
Art Unit 2891

IA

February 20, 2007

  
**B. WILLIAM BAUMEISTER**  
SUPERVISING PATENT EXAMINER  
TECHNOLOGY CENTER 2890